

J.C. PATENTS

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CERTIFICATE OF TRANSMISSION

March 11, 2003

Atty Docket No.: MART4591

Appl. No.

: 09/759,899

Filing Date

: January, 12, 2001

Pages

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BY FACSIMILE ONLY

Fax No.

703-872-9310

Attention

Examiner AHMED, SHAMIM

Group Unit: 1765

From

: Jiawei Huang, Reg. No. 43,330

MESSAGE: Enclosed is an Amendment in 6 pages.

Sir:

I hereby certify that this correspondence is being facsimile transmitted to the Patent and Trademark Office on March 11, 2003 at the above indicated fax number.

Sign by 1. (

Michelle Chang

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3-11-03: 4:35FM:

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Atty Docket No.: MART4591

Serial No.: 09/759,899

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Application No.

: 09/759,899

Filed

: January 12, 2001

For

: TREATMENT ON SILICON OXYGNITRIDE

Applicant

: I. T. Chen

Examiner

: Ahmed, Shamim

Art Unit

: 1765

No fee is believed to be due. However, the Commissioner is authorized to charge any fees required in connection with the filing of this paper to account No. 50-0710 (Order No. MART4591).

AMENDMENT AND RESPONSE TO OFFICE ACTION

BOX Non-Fee Amendment

Assistant Commissioner of Patents and Trademarks Washington, DC 20231

Dear Sir:

The Office Action mailed on December 12, 2002 has been carefully considered. In response thereto, please enter the following amendments and consider the following remarks.

In The Title:

Please substitute the following clean copy title for the pending title:

--METHOD TO REMOVE SILICON OXIDE MATERIAL GENERATED DURING REMOVAL OF PHOTORESIST--